

AMENDMENTS TO THE CLAIMS

1. **(Currently Amended)** A detergent composition for CIP, which comprises:
 (A) an aliphatic hydrocarbon solvent having 10 to 14 carbon atoms, and an SP value of 6 to 9 at 25°C; and
 (B) a surfactant comprising selected from an alkyl polyglycoside [[or]] and an alkyl glyceryl ether;
 water in an amount of 20 to 70 wt. %;
 wherein the amount of the solvent (A) is 3 to 70 wt. % of the total composition and the amount of the surfactant (B) is 10 to 70 wt. % of the total composition; and
 wherein the weight ratio of (A)/(B) is 30/70 to 70/30.
2. – 3. **(Cancelled)**
4. **(Previously Presented)** The detergent composition for CIP according to claim 1, wherein the SP value of the solvent (A) at 25°C is 7 to 8.
5. **(Cancelled)**
6. **(Withdrawn)** A CIP cleaning method which comprises the step of contacting a cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant with a material to be cleaned.
7. **(Withdrawn)** The CIP cleaning method according to claim 6, wherein the cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant is added to, and used in, an alkali detergent in a CIP process.

8. **(Withdrawn)** The CIP cleaning method according to claim 6, wherein the cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant is added to, and used in, an acid detergent in a CIP process.

9. **(Withdrawn)** The CIP cleaning method according to claim 6, wherein the cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant is added to, and used in, cleaning water in a CIP process.

10. **(Withdrawn)** The CIP cleaning method according to claim 6, which comprises a step (1) of contacting, at 60°C or more, a cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant with a material to be cleaned.

11. **(Withdrawn)** The CIP cleaning method according to claim 6, wherein the content of the solvent (A) is 0.01 to 20 wt%, and the content of the surfactant (B) is 0.01 to 20 wt%.

12. **(Withdrawn)** A CIP cleaning method which comprises a step (1) of contacting a cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant with a material to be cleaned and, thereafter, a step (2) of contacting a cleaning medium (II) comprising (A) a solvent having an SP value of 6 to 9 at 25°C at a concentration of less than 0.5 wt%, and (B) a surfactant, with the material to be cleaned.

13. **(Withdrawn)** The CIP cleaning method according to claim 12, which comprises the step (1) of adding the cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant to an alkali detergent in a CIP process, to contact it with a material to be cleaned, and, thereafter, the step (2) of adding the cleaning medium (II) comprising (A) a solvent having an SP value of 6 to 9 at 25°C at a concentration of less than 0.5 wt% and (B) a surfactant to an acid detergent in a CIP process to contact it with the material to be cleaned.

14. **(Withdrawn)** The CIP cleaning method according to claim 12, which comprises the step (1) of contacting, at 60°C or more, the cleaning medium (I) comprising (A) a solvent having an SP value of 6 to 9 at 25°C and (B) a surfactant with a material to be cleaned, and, thereafter, the step (2) of contacting, at 60°C or more, the cleaning medium (II) comprising (A) a solvent having an SP value of 6 to 9 at 25°C at a concentration of less than 0.5 wt% and (B) a surfactant with the material to be cleaned.

15. **(Withdrawn)** The CIP cleaning method according to claim 12, which comprises the step (1) of contacting a cleaning medium (I) comprising the solvent (A) in an amount of 0.01 to 20 wt% and the surfactant (B) in an amount of 0.01 to 20 wt% and the step (2) of contacting a cleaning medium (II) comprising the surfactant (B) in an amount of 0.01 to 30 wt%, which step (2) is carried out after the step (1).

16. **(Withdrawn)** The CIP cleaning method according to claim 6, wherein the surfactant (B) used in the step (1) or at least one of the surfactants (B) used in the steps (1) and (2), respectively, is selected from nonionic surfactants.

17. **(Withdrawn)** The CIP cleaning method according to claim 6, which comprises a step of judging acceptance or rejection by sensory evaluation of a rinse after the cleaning medium (I) or the cleaning mediums (I) and (II) have been used.

18. **(Withdrawn)** The CIP cleaning method according to claim 6, wherein the cleaning solution comprising the cleaning medium (I) or (II) is flowed at a flow rate of 0.5 to 5 m/sec.

19. **(Cancelled)**

20. **(Withdrawn)** A method of cleaning an object of CIP with the composition of claim 1.

21. **(Previously Presented)** The detergent composition for CIP according to claim 1, wherein the solvent (A) is an aliphatic hydrocarbon having 10 to 13 carbon atoms.

22. - 23. **(Cancelled)**

24. **(New)** The detergent composition for CIP according to claim 1, wherein the alkyl glyceryl ether is selected from the group consisting of 2-ethyl-hexyl glyceryl ether, octyl glyceryl ether, isodecyl glyceryl ether, decyl glyceryl ether, and dodecyl glyceryl ether.